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Structures and transistor properties of extended and unsymmetrical birhodanines†

Yuji Sumimoto,^a Kodai lijima,^a Dongho Yoo,^a‡ Tadashi Kawamoto,^a Yann Le Gal,^b Dominique Lorcy,^b and Takehiko Mori*^a

Birhodanines exhibit n-channel transistor properties with air stability. In this work, birhodanines with extended skeletons are investigated, in which a phenylene or quinoidal moiety is inserted in the central C=C part. We have also prepared N-phenyl and unsymmetrically N-substituted derivatives, including an unsubstituted N-H part. These compounds show n-channel transistor properties. In contrast to the herringbone structure of the parent compounds, the phenylene and phenyl compounds have stacking structures. The phenylene substitution decreases the acceptor ability, whereas quinoidal substitution improves the acceptor ability and air stability of the transistors. The N-H derivative has a Z-form, suggesting contribution of the enolic form, and unsymmetrically N-substituted derivatives have double-layer structures with ordered alkyl chains.

Introduction

Considerable attention has been paid to organic semiconductors used in organic transistors.¹ Although various high-performance materials have been proposed,2 there still remains a lot of room in nchannel materials showing air-stable operation.¹ Previously, we have reported air-stable n-channel transistor properties in 5,5'bithiazolidinylidene-2,4,2',4'-tetrathiones (Scheme 1, SS-R).^{3,4} These materials are obtained in the course of developing singlecomponent organic metals,⁵ but show strong acceptor ability with the lowest unoccupied molecular orbitals (LUMO) around -4.2 eV.⁴ The R = ethyl and propyl compounds (SS-Et and SS-Pr) exhibit excellently air-stable n-channel transistor characteristics. 3,4 Materials with longer alkyl chains show reduced performance,6 though single-crystal transistors of the pentyl compound exhibit a mobility of 1.1 cm² V⁻¹ s^{-1,7} In addition to these tetrathione derivatives, the 2,2'-dione-4,4'-dithione derivatives (OS-R) are regarded as a dimer of rhodanine, which is a well-known electron-deficient unit.⁸ Birhodanine is easily prepared by reacting alkyl amine, carbon disulfide, and dimethyl acetylene dicarboxylate for several minutes at room temperature.⁴ The

LUMO level of **OS-R** is located around -3.8 eV, which is a weaker electron acceptor than **SS-R**. **SS-R** has a stacking structure, whereas **OS-R** has a herringbone structure. **OS-R** shows similar transistor properties, though the performance and air stability are slightly reduced.

As an element of organic conductors, various π -extended molecules have been investigated. In particular, introduction of a quinoidal unit is a versatile tool to improve the donor/acceptor ability. In addition, even superconductivity has been found in vinylogous bis-fused tetrathiafulvalene. In Inspired by these findings, we have prepared π -extended birhodanines (Scheme 1). In 1, a phenylene unit is inserted in the central C=C part, whereas in 2 a quinoidal part is introduced. We have also developed a synthetic route to N-phenyl substituted compound, **OS-Ph**, and unsymmetrically N-substituted derivatives, **OS-RR'** containing different alky chains as well as an unsubstituted N-H part.

Scheme 1. Molecular structures of SS-R, OS-R, and the extended derivatives.

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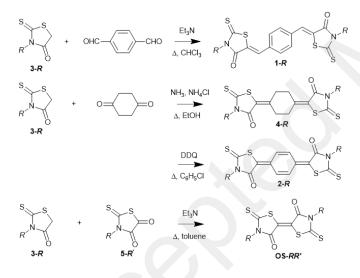
[†] Electronic Supplementary Information (ESI) available: Additional information for preparative details, structure analysis, devices fabrication, AFM images, and transistor characteristics. CCDC 2017521-2017527. For ESI and crystallographic

data in CIF or other electronic format see DOI: ‡ Present address: Department of Chemical Engineering and Center for Advanced Soft Electronics, Pohang University of Science and Technology, 77 Cheongam-Ro, Nam-Gu, Pohang 37673, Korea.

Table 1. Reduction potentials, energy levels, and optical gaps.

	$E_{\text{red}}\left(V\right)$	$E_{\text{LUMO}} (\text{eV})^{\text{a}}$	$\lambda_{\text{edge}} (\text{nm})^{\text{b}}$	Optical gap (eV) ^b	$E_{\rm HOMO}~({\rm eV})^{\rm a}$
OS-Et ⁴	-1.00	-3.80 (-3.80)	482 (438)	2.57 (2.8)	-6.37 (-6.44)
1-Pr	-1.17	-3.63 (-3.63)	472 (508)	2.63 (2.4)	-6.26 (-6.25)
1-Ph	-1.24	-3.56 (-3.56)	472	2.63	-6.19 (-6.28)
2-Me	-0.41	-4.21	624	1.99	-6.20
2-Et	-0.39	-4.23	621	2.00	-6.23
2-Pr	-0.40	-4.20	607	2.04	-6.24
2-Bu	-0.40	-4.20	617	2.00	-6.20
2-Ph	-0.39	-4.20	623	1.99	-6.19
OS-Ph	-0.68	-3.95 (-3.80)	508	2.53	-6.48 (-6.34)
OS-EtH	-0.64	-3.98	508	2.44	-6.42
OS-BuH	-0.62	-4.00 (-3.88)	514	2.41	-6.41 (-6.72)
OS-EtMe	-0.96	-3.84 (-3.61)	493	2.51	-6.35 (-6.39)
OS-PrMe	-0.96	-3.84	493	2.51	-6.35
OS-BuMe	-0.96	-3.84 (-3.81)	487	2.54	-6.38 (-6.48)
OS-PrEt	-0.97	-3.83 (-3.80)	489	2.53	-6.36 (-6.49)

^a The LUMO levels were estimated from the first reduction potentials by assuming the reference energy level of ferrocene/ferrocenium to be 4.8 eV from the vacuum level. ¹⁷ The HOMO levels were obtained by subtracting the optical gaps from the LUMO levels. The values in the parentheses were calculated by using the ADF software with the B3LYP* functional and TZP basis set. ¹⁸ The values in the parentheses were from absorption of the thin films.



Scheme 2. Preparation of 1-R, 2-R, and OS-RR'.

Results and discussion

Preparation

n-Propyl and phenyl rhodanines **3-R** were obtained from the dithiocarbamate and chloroacetic acid. Similarly to the previous reactions, the rhodanines were reacted with terephthalaldehyde in the presence of triethylamine to afford **1-R** (Scheme 2). In order to prepare **2-R**, rhodanines **3-R** (R = Pr, Bu, and Ph) were reacted with 1,4-cyclohexanedione in the presence of ammonia. The resulting **4-R** was reacted with 2,3-dichloro-5,6-dicyano-p-

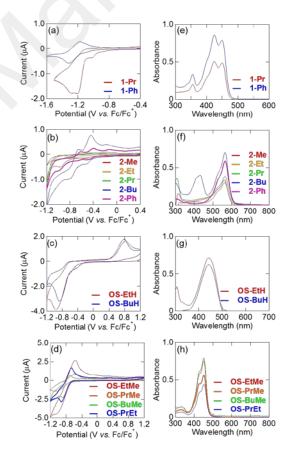


Fig. 1. Cyclic voltammograms of (a) **1-** R_1 (b) **2-** R_1 (c) **OS-**RH, and (d) **OS-**RR', measured in n-Bu₄N·PF₆/CH₂Cl₂(50 mV s⁻¹). Normalized absorption spectra of (e) **1-** R_1 , (f) **2-** R_1 , (g) **OS-** RH_2 , and (h) **OS-**RR', measured in DMF.

Table 2. Crystallographic data.

	1-Pr	1-Ph	OS-Ph	OS-BuH	OS-EtMe	OS-BuMe	OS-PrEt
Formula	$C_{20}H_{20}N_2O_2S_4$	$C_{22}H_{18}N_2O_2S_4$	$C_{18}H_{10}N_2O_2S_4$	$C_{10}H_{10}N_2O_2S_4$	$C_9H_8N_2O_2S_4$	$C_{11}H_{12}N_2O_2S_4\\$	$C_{11}H_{12}N_2O_2S_4\\$
Formula weight	448.63	516.66	414.53	318.44	304.41	332.47	332.47
Crystal System	Triclinic	Monoclinic	Triclinic	Monoclinic	Monoclinic	Monoclinic	Monoclinic
Space Group	P-1	$P2_{1}/n$	P-1	$P2_{1}/n$	$P2_{1}/c$	$P2_{1}/c$	$P2_{1}/c$
Shape	Orange prism	Orange needle	Orange plate	Orange needle	Orange plate	Orange plate	Orange plate
a (Å)	5.868(4)	12.6138(4)	4.8107(4)	14.3245(9)	11.429(4)	26.578(7)	25.445(6)
b (Å)	9.531(6)	5.52905(16)	9.0732(6)	4.9698(3)	7.888(3)	7.813(3)	8.045(2)
c (Å)	10.618(6)	16.8453(5)	11.0382(6)	19.9041(12)	7.254(3)	7.2475(12)	7.101(2)
α (deg.)	107.56(5)	90	108.240(3)	90	90	90	90
β (deg.)	93.87(6)	100.868(2)	98.143(4)	106.593(3)	99.20(3)	93.773(17)	93.45(2)
γ (deg.)	106.20(6)	90	96.693(4)	90	90	90	90
$V(\mathring{A}^3)$	536.2(7)	1153.76(6)	446.30(5)	1357.94(14)	645.6(7)	1501.7(7)	1451.0(9)
Z-value	1	2	1	4	2	4	4
T(K)	295	275	275	274	297	297	297
$D_{ m calc}$ (g cm $^{-3}$)	1.389	1.487	1.542	1.557	1.566	1.470	1.522
Total reflns.	3667	12276	4892	13966	1461	3359	3177
Unique reflns. (R_{int})	3131 (0.0563)	2098 (0.0890)	1611 (0.1151)	2393 (0.1548)	1144 (0.0950)	2727 (0.0196)	2572 (0.0664)
$R_1 [F^2 > 2\sigma(F^2)]$	0.0447	0.1024	0.0796	0.0740	0.0563	0.0431	0.0447
wR_2 [All reflns.]	0.1240	0.3367	0.2371	0.2123	0.1713	0.1402	0.1402
GOF	0.986	1.235	0.972	0.876	1.034	1.018	1.014
Interplanar spacing (Å)	3.587	3.410	3.550	3.404	3.157	3.120	3.273

benzoquinone (DDQ) to give **2-R**. **OS-Ph** was not obtained by the direct reaction of aniline with carbon disulfide and dimethyl acetylene dicarboxylate.⁴ Instead, rhodanine **3-Ph** was condensed with isatine **5-Ph** to afford **OS-Ph**.¹⁶ The same reaction was applied to prepare unsymmetrically substituted **OS-RR'** (RR' = EtMe, PrMe, BuMe, and PrEt). Using this route, we can also obtain *N*-unsubstituted compounds (RR' = EtH and BuH). Among these compounds, **1-Pr**, **2-Pr**, and unsymmetrical compounds are new compounds.

Electrochemical properties

Cyclic voltammetry of these compounds shows clear reduction waves (Fig. 1), from which the LUMO levels are estimated as listed in Table 1. Compound 1 is a weaker acceptor than the parent **OS-R** due to the insertion of a phenyl ring. By contrast, 2 is a stronger acceptor than **OS-R** in agreement with the quinoidal structure, which is as strong as **SS-R**. Optical gaps of 1 are slightly larger than **OS-R**, whereas those of 2 are significantly smaller than **OS-R**. As a result, the LUMO levels largely depend on the π -extension manner, though the highest occupied molecular orbital (HOMO) levels of these compounds are approximately the same.

OS-Ph and **OS-RH** are slightly stronger acceptors than **OS-Et**, indicating the alkyl groups are weakening the acceptor ability. The reduction of **OS-RH** is, however, somewhat irreversible.

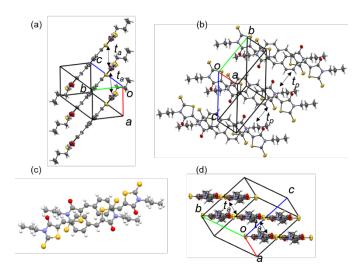


Fig. 2. Crystal structure of **1-Pr**, (a) viewed along the molecular short axis, (b) viewed perpendicular to molecular plane, (c) molecular overlap mode, and (d) viewed along the molecular long axis. Transfer integrals of the LUMO–LUMO interactions are a = 2.3 and p = 0.1 meV.

Crystal structures

X-ray single crystal structure analyses were carried out for 1-Pr, 1-Ph, OS-Ph, OS-BuH, OS-EtMe, OS-BuMe, and OS-PrEt. The crystal data are listed in Table 2.

1-Pr is a planar molecule except for the propyl chains (Fig. 2). A molecule is located on an inversion center, and a half molecule is crystallographically independent. The molecules are uniformly stacked along the a axis (Fig. 2(a)) with a large tilt angle (45°) of the molecular long axis from the stacking (a) axis. The molecular long axis does not correspond to neither the b or c axis (Fig. 2(b)). In the stack, the molecules are largely displaced both along the molecular long and short axes (Fig. 2(c)), in which a thiazol sulfur is located approximately on the top of the central phenylene ring. The molecules are stacked with a short axis displacement similar to **SS-R** crystals (Fig. 2(d)). There are short S-S contacts, 3.64 and 3.94 Å along the stack. The intrachain transfer is comparatively small, but the interchain transfers are even smaller (Fig. 2).

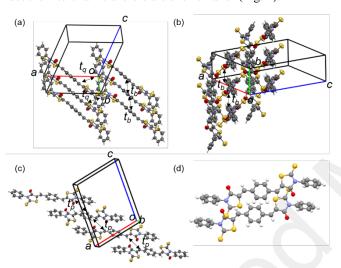


Fig. 3. Crystal structure of **1-Ph**, (a) viewed along the molecular short axis, (b) viewed along the molecular long axis, (c) viewed along the b axis, and (d) molecular overlap mode. Transfer integrals of the LUMO-LUMO interactions are b = 51.3, p = 0.4, and q = 12.9 meV.

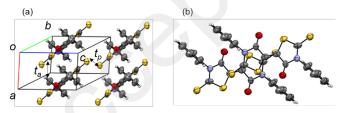
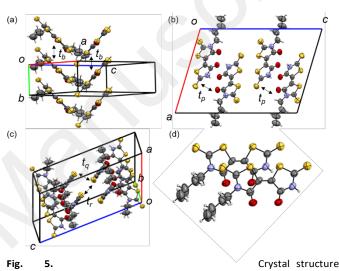


Fig. 4. Crystal structure of **OS-Ph**, (a) viewed along the molecular long axis, and (b) molecular overlap mode. Transfer integrals of the LUMO–LUMO interactions are a = 140.9 and p = 10.2 meV.

1-Ph has a planar core, though the terminal phenyl groups are tilted by 71.9° from the core part (Fig. 3). A molecule is located on an inversion center, and a half molecule is crystallographically independent. The molecules are uniformly stacked along the b axis (Fig. 3(a)), where the molecular long

axes are 26° tilted from the stacking (*b*) axis. Owing to the monoclinic symmetry, molecules in the adjacent stacks are tilted in the opposite directions (Fig. 3(b)), where the interchain contacts run along the a+c axis (Fig. 3(c)). In the stack, the molecules are more largely displaced both along the molecular long and short axes (Fig. 3(d)). There are short S–S contacts, 3.63 and 4.04 Å, and significant intra- and inter-chain transfer integrals (Fig. 3).

OS-Ph has a planar core, though the terminal phenyl groups are tilted by 78.4° from the core part (Fig. 4). A half molecule is crystallographically independent, and a molecule is located on an inversion center. Then, all molecules are parallel to each other, and stacked along the *a* axis (Fig. 4(a)). Accordingly, the packing pattern resembles **SS-R** rather than the herringbone **OS-R**. There are S-S contacts, 3.82, 4.01 and 4.02 Å along the stack, and a considerable intrachain transfer integral (Fig. 4).



of **OS-BuH**, (a) molecular overlap mode, (b) viewed along the b axis, (c) viewed along the molecular short axis, and (d) viewed along the molecular long axis. Transfer integrals of the LUMO–LUMO interactions are b = 49.9, and p = 19.1, q= 5.3, and r = 12.7 meV.

As shown in Fig. 5, unsymmetrically substituted **OS-BuH** has a planar core (Figs. 5(a) and (b)), but the sulfur atoms are located on the same side (*Z*-form). Since the O···O distance is as small as 2.748 Å, we have to suspect hydrogen bonding, where the nitrogen H moves to O (Fig. S2). Although the ketone form is preferable to the enolic form in the crystal structure analysis, the contribution of the enolic form may be related to the *Z*-configuration.

The molecules are uniformly stacked along the b axis (Fig. 5(c)). The molecular long axes are parallel to the a axis (Fig. 5(b)), and the interchain interactions are along the c axis. In the stack, the molecules are largely displaced both along the molecular long and short axes (Fig. 5(a)); this overlap mode is very similar to **SS-R**. The tilt angle of the molecular long axis from the stacking (b) axis is 33° (Fig. 5(c)), but every two columns are tilted in the opposite directions (Fig. 5(d)). Accordingly, molecules in the central two columns in Figs. 5(b) and (d) are parallel to each other; this part has the same (β "-like) structure as **SS-R**. There are many S-S contacts in this

interstack direction, 3.73, 3.78, 3.84, and 3.98 Å between these parallel molecules because the sulfur atoms are aligned in the same side. These are shorter than the intrastack S–S contacts of 3.94 and 4.06 Å. Transfer in this intercolumnar direction (*p*) is considerably large, and a two-dimensional network is formed.

OS-EtMe, OS-BuMe, and OS-PrEt have herringbone structures with the same space group (Fig. 6(a)), but are not entirely isostructural. OS-EtMe has a single layer structure along the a axis, whereas OS-BuMe and OS-PrEt have a double layer structure (Fig. 6(b)). This is because the methyl and ethyl groups in OS-EtMe are disordered, but other alkyl groups are ordered. In the symmetrical OS-R, the layers are alternately tilted in even R, but entirely parallel in odd R. In OS-BuMe and OS-PrEt, all layers are parallel, but still make a double layer structure because the longer alkyl chains are Since the dihedral oriented to the same interlayer spacing. angle tends to increase with increasing the alkyl chain,⁴ the observed dihedral angles (Table 3) are in the similar level to the symmetrical molecules. In contrast to the symmetrical **OS-R**, t_c is larger than the diagonal transfer integrals, t_p and t_q , but forms a balanced two-dimensional network.

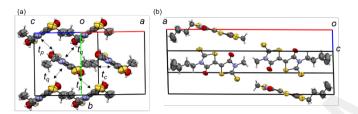


Fig. 6. (a) Crystal structure of **OS-EtMe** viewed along the molecular long axis. (b) Crystal structure of **OS-BuMe** viewed along the molecular short axis.

Table 3. Dihedral angles and transfer integrals (meV) in OS-RR'.

	Dihedral angle	t_c	t_p	t_q	Tilt angle
OS-MeEt	62°	31.4	17.1	18.0	17°
OS-MeBu	61°	37.8	20.1	22.3	$17^{\rm o}$
OS-EtPr	66°	49.1	9.18	11.4	19°

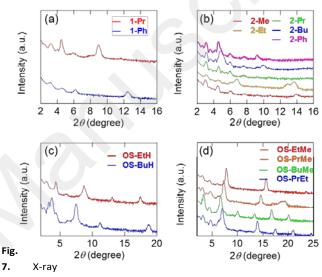
Thin film properties

Evaporated films of **1-Pr** and **1-Ph** show X-ray diffraction (XRD) peaks (Fig. 7(a)). However, d = 19.8 Å of **1-Pr** does not agree with the crystal lattice (Table 2). Since the molecular length is estimated to be l = 20.8 Å from the crystal structure, the tilt angle θ in the thin film is expected to be $\theta = 19.8^{\circ}$ by using $l = d/\cos\theta$. The thin film structure is potentially different from the single-crystal structure. For **1-Ph**, d = 14.2 Å is not far from a + b = 13.8 Å, corresponding to the molecular long axis (Fig. 3(c)). Then, the thin film structure is not largely different from the crystal structure.

XRD of **2-R** (R = Me, Et, Bu, and Ph) exhibit peaks at d = 12.7, 13.0, 17.8, and 19.2 Å, respectively (Fig. 7(b)); these d values approximately correspond to the molecular lengths. Although

crystal structures of these compounds have not been determined due to the comparatively poor crystallinity, these compounds construct ordinary layer structures.

The unsymmetrical **OS-RR**' show sharp XRD peaks with many higher-order peaks (Figs. 7(c) and (d)). The peaks around 4° in **OS-EtH** and **OS-BuH** correspond to d = 20.1 and 23.5 Å, respectively, indicating the double layer structures. The peaks around 8° in **OS-EtMe, OS-PrMe, OS-BuMe**, and **OS-PrEt** correspond to 11.3, 12.1, 13.3, 13.6 Å, in agreement with the crystal a axis (Table 2). Then, the molecules are tilted from the substrate normal by an angle of $17\sim19^{\circ}$ (Table 3), which are in the same order as $18\sim19^{\circ}$ in the symmetrical molecules.⁴ **OS-BuMe** shows a clear peak at 4° , indicating the double layer structure. The low-angle peak is less obvious in other **OS-RR**'.



diffraction pattern of (a) 1-R, (b) 2-R, (c) OS-RH, and (d) OS-RR'.

Atomic force microscopic (AFM) images show highly crystalline morphology (Fig. 8). **1-Pr** shows comparatively loose packing of large crystals (Fig. 8(a)). **OS-RR'** shows large crystals, which are consistent with the sharp XRD peaks, but large inter-grain space may be related to the transistor performance.

Table 4. Characteristics of thin-film transistors.

-		$\mu_{\rm max} ({\rm cm}^2 {\rm V}^{-1} {\rm s}^{-1})$	$\mu_{\text{ave}} (\text{cm}^2 \text{V}^{-1} \text{s}^{-1})$	$V_{ m th}\left({ m V} ight)$	On/off ratio
1-Ph	under vacuum	0.019	0.013	76	7 x 10 ⁵
	in air	1.4 x 10 ⁻⁴	9.8 x 10 ⁻⁵	153	3×10^4
2-Me	under vacuum	5.0 x 10 ⁻⁵	3.4 x 10 ⁻⁵	-4	6×10^{2}
2-Et	under vacuum	0.041	0.038	4	2×10^4
	in air	0.028	0.026	12	70
2-Bu	under vacuum	9.3 x 10 ⁻⁵	5.8 x 10 ⁻⁵	38	3 x 10 ⁴
	in air	3.7 x 10 ⁻⁵	2.2 x 10 ⁻⁵	35	2×10^{3}
OS-Ph	under vacuum	8.3 x 10 ⁻⁵	6.5 x 10 ⁻⁵	40	8 x 10 ⁴
	in air	5.0 x 10 ⁻⁵	4.0 x 10 ⁻⁵	65	1×10^{3}
OS-EtH	under vacuum	5.5 x 10 ⁻⁴	3.9 x 10 ⁻⁴	63	5 x 10 ⁵
	in air	2.7×10^{-5}	2.7 x 10 ⁻⁵	86	3×10^{2}
OS-BuH	under vacuum	3.6 x 10 ⁻³	2.7 x 10 ⁻³	55	2 x 10 ⁶
	in air	7.3×10^{-4}	6.0×10^{-4}	68	4×10^4
OS-EtMe	under vacuum	3.4 x 10 ⁻⁵	2.1 x 10 ⁻⁵	59	5×10^{2}
OS-PrMe	under vacuum	0.019	0.015	65	6×10^6
	in air	4.3×10^{-3}	2.4 x 10 ⁻³	81	5×10^{5}
OS-BuMe	under vacuum	0.024	9.6 x 10 ⁻³	55	2×10^{5}
	in air	1.3 x 10 ⁻³	8.7 x 10 ⁻⁴	94	2×10^4
OS-PrEt	under vacuum	0.013	0.010	45	2×10^{6}
	in air	7.1×10^{-3}	4.3×10^{-3}	78	5×10^{5}

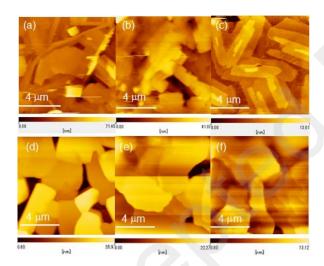


Fig. 8. Atomic force microscopic (AFM) images of (a) 1-Pr (b) 2-Et (c) OS-BuH, (d) OS-EtMe, (e) OS-BuMe, and (f) OS-PrEt.

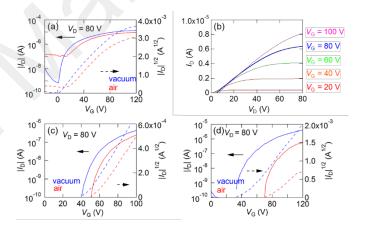


Fig. 9. (a) Transfer and (b) output characteristics of **2-Et** thin-film transistors measured under vacuum (blue) and in air (red). Transfer characteristics of (c) **OS-BuH**, and (d) **OS-PrEt**.

Transistor properties

These compounds show n-channel transistor properties as exemplified by Fig. 9. From the characteristics, the transistor parameters are extracted as listed in Table 4. **2-Et** shows maximum mobility of $0.041 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, which is not largely different from $0.15 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ in **OS-Et**.⁴ This transistor shows reasonable air stability. Although the off current increases considerably, the drop of the on current is not significant. As a result, the on/off ratio drops sometimes more than one order, but the mobility does not drop to half. Since mobilities of **OS-R** transistors drop typically four times in air,⁴

meaningful improvement of air stability is observed. In addition, although **OS-R** transistors show comparatively large threshold voltages, **2-Et** exhibits a small threshold voltage. This is attributed to the drop of the LUMO levels from -3.8 eV to -4.2 eV due to the introduction of the quinoid structure (Table 1). The resulting LUMO level is as low as **SS-R**, although the air stability is not comparable to **SS-R**. The mobility of **OS-Ph** is not high, but the drop in air is comparatively small. This seems again to be associated with the relatively low LUMO level (-3.95 eV) as well as the same type of molecular packing as **SS-R** (Fig. 4).

1-Ph shows transistor properties, but **1-Pr** does not show transistor properties. This is ascribed to the very small intermolecular transfers (Fig. 2). However, the performance of the **1-Ph** transistor decreases two orders of magnitude in air. This is reasonable in view of the high LUMO level (-3.6 eV). We have also prepared **OS-Ph**, but the transistor properties are not significant. This may be related to the stacking structure with extremely one-dimensional interaction (Fig. 4).

Unsubstituted compounds, **OS-EtH** and **OS-BuH**, do not seem preferable to transistor performance. **OS-BuH** exhibits moderate transistor performance (Table 4), but the performance drops in air, reflecting the LUMO level of $-4.0 \, \text{eV}$. In general, **OS-PrMe**, **OS-BuMe** and **OS-PrEt** show mobilities around $0.02 \, \text{cm}^2 \, \text{V}^{-1} \, \text{s}^{-1}$. This is not as large as $0.15 \, \text{cm}^2 \, \text{V}^{-1} \, \text{s}^{-1}$ in **OS-Et**, but comparable to $0.05 \, \text{cm}^2 \, \text{V}^{-1} \, \text{s}^{-1}$ in **OS-Pr** with similar *R* length.⁴ This is also contrasting to the reduced performance of disordered **OS-EtMe**. Although the double layer structure does not significantly improve the mobility as unsymmetrical benzothienobenzothiophene (BTBT), ¹⁹ it is important to maintain the ordered structure. Large threshold voltage is, however, unavoidable in **OS-RR**'. In this context, **2-Et** shows a significant improvement.

Conclusions

We have prepared birhodanine molecules with extended π -skeletons. Compounds **2** with quinoid skeleton realize as strong acceptor ability as **SS-R**, and the air stability of the transistor performance and the threshold voltage are improved. Since the preparation of **OS-R** is easier than **SS-R** in general, this is a versatile way to obtain an air-stable n-type material. In contrast, **1-R** shows decreased acceptor ability and (β "-type) stacking structures with short-axis displacement. Together with **OS-Ph** and **OS-BuH**, this stacking structure resembles **SS-R** rather than the herringbone **OS-R**.

We have developed a method to prepare unsymmetrical **OS-**RR', including R = H and Ph, which are not accessible in the conventional method. N-H and N-Ph compounds show a slight improvement of the acceptor ability. The Z-form of **OS-BuH** is probably related to the contribution of hydrogen bond of the enolic form, and the enhanced S-S interaction is not too disadvantageous to the carrier transport despite the lowered symmetry. Basically, unsymmetrical **OS-**RR' has double-layered herringbone structures, ¹⁹ and the ordered structure achieves comparable transistor performance to the symmetrical **OS-**R.

Conflicts of interest

There are no conflicts to declare.

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